



INTERNATIONAL
GEMOLOGICAL
INSTITUTE

ELECTRONIC COPY

LABORATORY GROWN DIAMOND REPORT

August 25, 2026

IGI Report Number
Description
Shape and Cutting Style
Measurements

LG830604834
LABORATORY GROWN DIAMOND
OVAL BRILLIANT
7.74 X 5.59 X 3.67 MM

GRADING RESULTS

Carat Weight
Color Grade
Clarity Grade

1.01 CARAT
E
VS 1

ADDITIONAL GRADING INFORMATION

Polish
Symmetry
Fluorescence

EXCELLENT
EXCELLENT
NONE

Inscription(s)

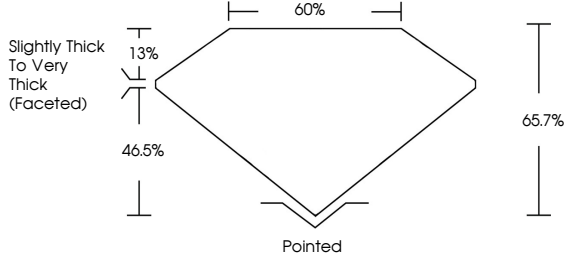
Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa

 LG830604834

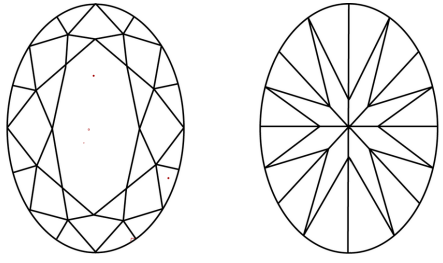
LG830604834

Report verification at igi.org

PROPORTIONS



CLARITY CHARACTERISTICS



KEY TO SYMBOLS

Red symbols indicate internal characteristics.
Green symbols indicate external characteristics.

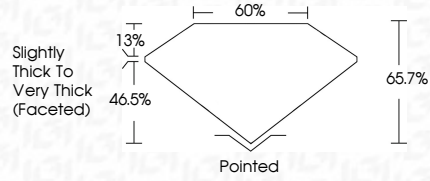
COLOR

CLARITY

D	E	F	G	H	I	J	Faint	Very Light	Light
CLARITY									
FL	IF	VVS ¹⁻²	VS ¹⁻²	SI ¹⁻²	I ¹⁻³				
Flawless	Internally Flawless	Very Very Slightly Included	Very Slightly Included	Slightly Included	Included				



Sample Image Used



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EXCELLENT
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OVAL BRILLIANT

7.74 X 5.59 X 3.67 MM

Carat Weight
Color Grade
Clarity Grade
Depth
Table
Girdle

1.01 CARAT
E
VS 1
65.7%
60%
Slightly Thick To Very Thick (Faceted)

Pointed
EXCELLENT
EXCELLENT
NONE

Polish
Symmetry
Fluorescence
Inscription(s)

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